# Supporting Information for: Temperature-dependent adhesion of graphene suspended on a trench

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## **Cross-section of sheet deposited at** T = 0

At zero temperature, the detached part of the sheet is not entirely flat in its cross section, and a low-amplitude ripple can be seen. Figure S1 shows a cross-section taken 1.5 nm from the trench edge for a sheet with adhesion  $\varepsilon = 0.1$  eV.

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### Alternative temperature protocol

In the majority of simulations, we have first deposited and relaxed a sheet on the substrate at T = 0 before raising the temperature slowly, as described in the main text. However, we have also tested an alternative protocol in which the sheet is relaxed away from the substrate at T = 300 K, then deposited and relaxed, before the temperature is slowly lowered using a Berendsen thermostat, see the included video cool\_from\_T300.avi. The interaction with the substrate is characterized by  $\varepsilon = 0.04$  eV. Measurements are made by averaging over configurations while the sheet is held at constant temperature using a Langevin thermostat. The change in depth is T is consistent with results from the heating protocol, although the absolute depth is smaller, as shown in Fig. S2.

### **Example videos of sheet deposition and fluctuations**

We include four videos. In all cases the trench has width 15 nm and edges of radius of curvature r = 1 nm, with adhesion  $\varepsilon = 0.04$  eV:

- deposition\_T0.avi shows the initial relaxation of a sheet deposited at T = 0,
- steady-state\_T200.avi shows steady state fluctuations at T = 200 K,
- steady-state\_10T00.avi shows steady state fluctuations at T = 1000 K,
- cool\_from\_T300.avi shows deposition and cooling of a sheet initially at 300 K, with the temperature ramped down to 0.

### Role of trench width in the 1d model

We have tested how the depth *h* of the sheet center varies as the trench width *l* and sheet length *L* are simultaneously increased at T = 0, for a sheet with width  $w = 1.93 \ \mu m$  (based on the system studied experimentally by Bunch *et al*<sup>1</sup>). We find the depth grows sublinearly with *L*.

# **Resonance frequency of large sheets**

The fundamental frequency f of a string of length L, mass density m and under tension t is

$$f = \frac{\sqrt{t/m}}{2L}.$$
(1)

We calculate this frequency using the T = 0 configuration of our 1d model with  $\varepsilon = 0.04$  eV. We treat the sheet as a line with  $m = w\rho m_C$  where w is the sheet width,  $\rho$  the number density of atoms and  $m_C$  the mass of a carbon atom. The tension t is calculated from the strain in the detached sheet. Figure S5 shows the calculated f for a range of trench rim radii of curvature r, for a sheet of width 1.93  $\mu$ m over a trench of width 1.1  $\mu$ m, values taken from Bunch *et al*'s experimental work.<sup>1</sup> In that work, a resonance frequency of 70.5 MHz was found (Fig. 2B).

#### References

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 Bunch, J. S.; van der Zande, A. M.; Verbridge, S. S.; Frank, I. W.; Tanenbaum, D. M.; Parpia, J. M.; Craighead, H. G.; McEuen, P. L. *Science* 2007, *315*, 490–493



Figure S1: Cross-section taken 1.5 nm from the trench edge for a sheet with adhesion  $\varepsilon = 0.1$  eV.



Figure S2: Depth of the center of the sheet, h, plotted against temperature T.



Figure S3: Temperature dependence of the mean stress along the long axis, measured in the sheet center.



Figure S4: Depth of the sheet center in the 1d model at T = 0, in the case L = l and  $w = 1.93 \ \mu m$ , for adhesion  $\varepsilon$  (in eV) as reported in the legend.



Figure S5: Fundamental frequency f for a sheet of width 1.93  $\mu$ m suspended over a trench of width 1.1  $\mu$ m with adhesion energy  $\varepsilon = 0.04$  eV, plotted against trench edge curvature r.